

Characterization of O₂ ionosorption induced potential changing property of SnO₂ nanowire with Kelvin force microscopy (KFM)

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We have employed Kelvin force microscopy (KFM) system to measure the potential change of a single SnO₂ nanowire which had been synthesized on the Au thin film by a thermal process. By using the KFM probing technique, Rh coated conducting cantilever can approach a single SnO₂ nanowire in nano scale and get the potential images with oscillating AC bias between Au electrode and cantilever. Also, during imaging the potential status, we controlled the concentration of oxygen in measuring chamber to change the ionosorption rate. From the results of such experiments, we verified that the surface potential as well as doping type of a single SnO₂ nanowire could be changed by oxygen ionosorption.

Key words: Tin-oxide (SnO₂), nanowire, gas sensor, Conductive -AFM, Kelvin force microscopy (KFM).

Introduction

Tin oxide (SnO₂) nanowire is a one of the most widely using materials for the fabrication of various gas (O₂, CO, NO_x) detecting devices. Basically, the SnO₂ shows an n-type semiconductor property with a wide band gap, about 3.99 eV. Also, SnO₂ thin film has been known as a transparent metal oxide electrode and it is applicable for a various mobile or flexible electronic parts. Nowadays, the characterization and application of SnO₂ nanowire is performed actively since it is possible to manufacture a micro-sensor array with conventional silicon processing. However, to align a single SnO₂ nanowire on the specific site for the fabrication of integrated gas sensor device is a difficult problem. Also it is not easy to characterize the electrical property of single SnO₂ nanowire with a conventional electronic device analyzing method. To achieve a high-performance gas-sensing property with SnO₂, we have to verify a potential variation that is result from the ionosorption effect in different oxygen concentration ambient [1, 2]. In this study, Kelvin force microscopy (KFM) system has been employed to measure the potential change of a single SnO₂ nano-wire which had been synthesized on the Au thin film by a thermal process [3, 4]. By using the KFM probing technique, Rh coated conducting cantilever can approach a single SnO₂ nanowire in nano scale and get the potential images with oscillating AC bias between Au electrode and cantilever. Also, during imaging the potential status, the concentration of oxygen was varied in measuring

chamber to change the ionosorption rate. The experimental results verified that oxygen detectability of single SnO₂ nanowire would be necessary for the realization of high-performance gas-sensing device.

Experimental

SnO₂ nanowires were synthesized on the Au deposited Si wafer substrate by a VLS (vapor-liquid-solid) method. At first, 5 nm thick Au thin film was deposited on the p-type Si wafer with a sputtering method. The Au thin film was used as a catalyst for a SnO₂ nanowire. Alumina boat has been filled with Sn powder (325MESH, 99.8% purity, Acros Organics) and placed in the center of quartz tube. During the nanowire synthesis, the inner pressure of furnace has been maintained at 1 torr with a inlet gas ratio of Ar : O₂ = 610 : 40. Nanowires were grown in 750 °C for 40 min. Fig. 1 shows a schematic of SnO₂ nanowire synthesizing furnace and KFM measurement system.

The shape and morphology of synthesized nanowires were observed with a field emission scanning electron microscopy (FE-SEM, Jeol JSM-6700F) and scanning probe microscopy (SPM, Seiko, E-Sweep NanoNavi II). Also its crystalline structures were analyzed by X-ray Diffraction (XRD, Bruker D8).

To characterize the electrical property of a single SnO₂ nanowire, we needed to separate it from the surface of Si wafer and disperse into solution. The film-like synthesized nanowires were separated in the ethanol by a sonication and its solution has been dispersed on the Au (50 nm) / SiO₂ (200 nm)/p-type Si substrate [5]. And then we employed KFM to measure and evaluate a surface potential change of nanowire. The potential images have been attained under AC bias oscillating from -2.5 V to +2.5 V using a conductive

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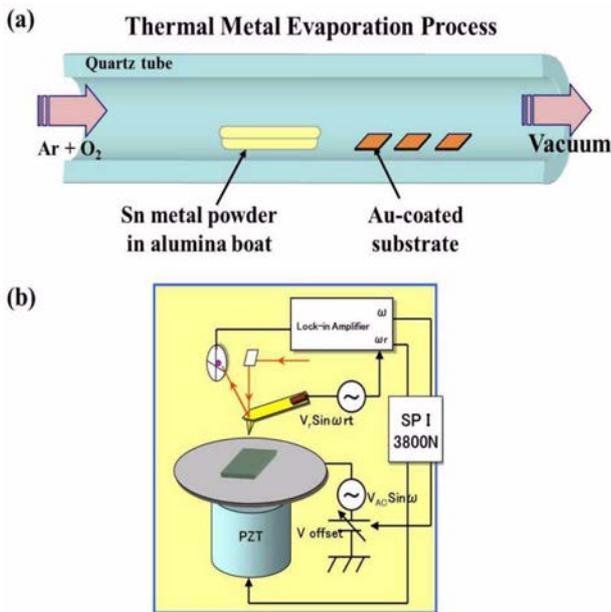


Fig. 1. Schematic of (a) SnO_2 nano-wire synthesizing furnace and (b) KFM measurement system.

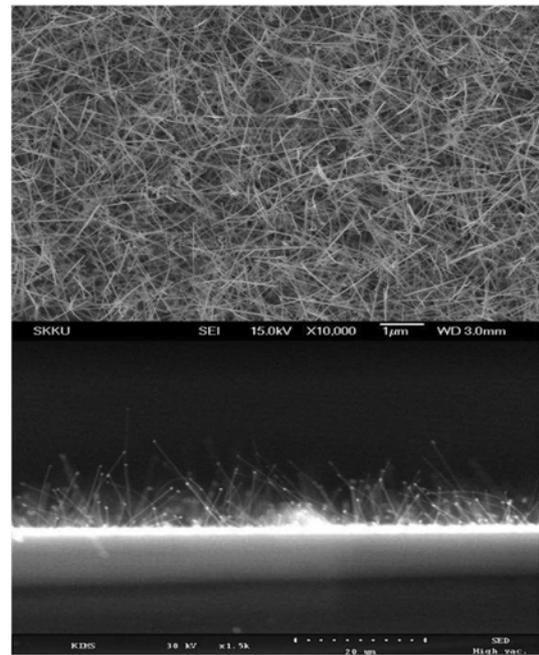


Fig. 2. In-plane and cross-sectional SEM images of SnO_2 nanowire.

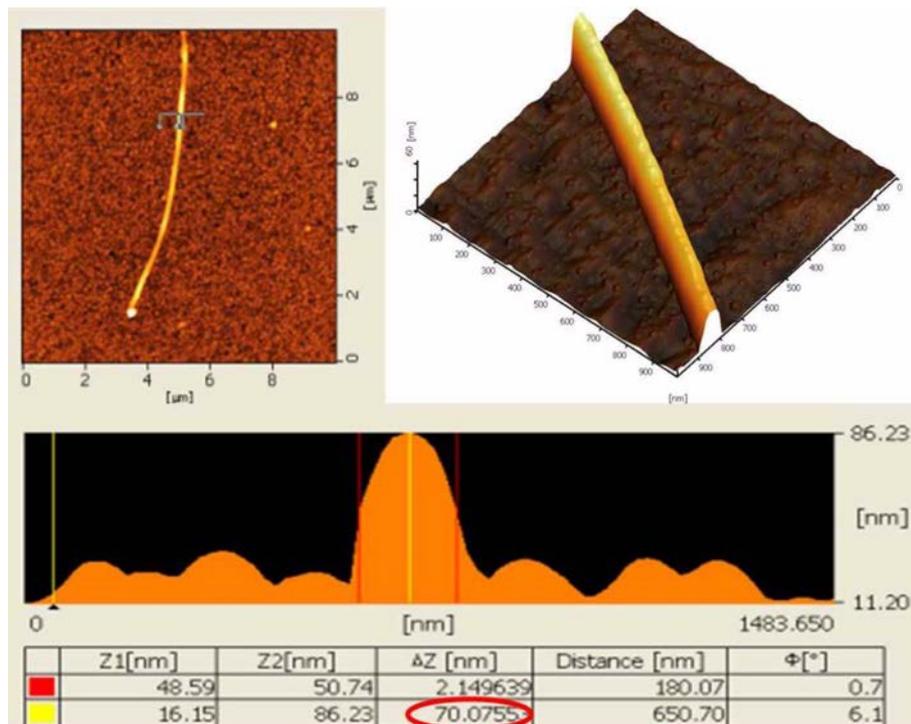


Fig. 3. Topological analysis of single SnO_2 nanowire and 3D SPM images.

metal coated cantilever tip. From the results, the change of surface potential was calculated. To verify effect of O_2 ionosorption into SnO_2 nanowire, we controlled the atmosphere condition of sample chamber. First of all, we have measured the KFM images of as-synthesized SnO_2 nanowire. And then O_2 gas was supplied to the chamber with a flow rate from 0 to 300 sccm. Lastly, to verify effect of O_2 ionosorption on the

surface potential of SnO_2 nanowire, the KFM analysis has been performed again.

Results and Discussion

Figs. 2 and 3 show SEM images of as-synthesized film of SnO_2 nanowire and topological SPM analysis of single nanowire, respectively. SEM Images shows a

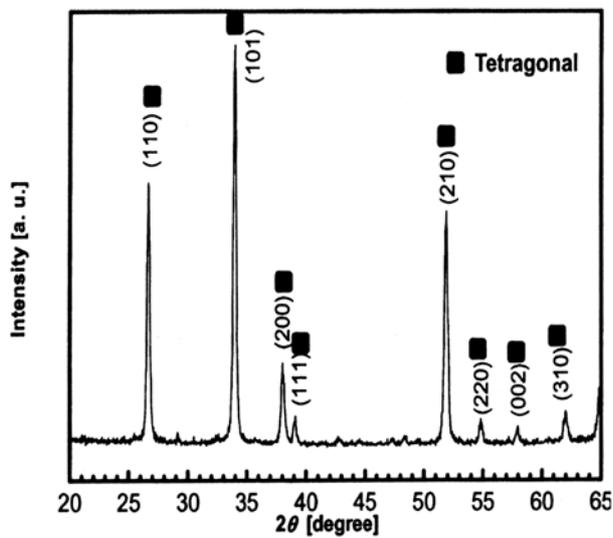


Fig. 4. X-ray diffraction patterns of as-synthesized SnO₂ nanowires.

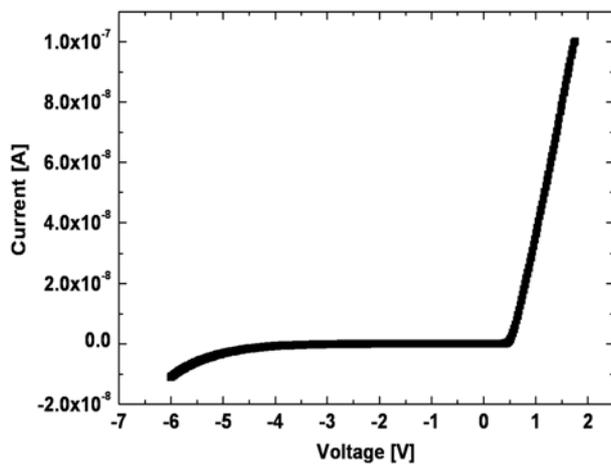


Fig. 5. Schottky diode property of n-type semiconducting as-synthesized SnO₂ nanowires.

tip of Au catalyst at the end of nano-wires. It means that nano-wires were synthesized by a vapor-liquid-solid (VLS) growing mechanism [3, 4]. As shown in Fig. 3, a length and diameter of single nanowire which used in I-V measurement was measured to be 4 μm and 53 nm, respectively.

The XRD analysis was performed to know a crystalline structure and diffraction signal of (110), (101), (200), (111), (210), (220), (002), (310) planes are measured. From these results, lattice parameter of rutile crystal structured SnO₂ nanowire was calculated to be $a = b = 4.734 \text{ \AA}$ and $c = 3.185 \text{ \AA}$. (JCPDS card number 21-1250) [5]

In the previous research paper, by measuring an I-V characteristic of metal-semiconductor-metal Schottky diode structure of single SnO₂ nanowire which dispersed on the Au (50 nm) / SiO₂ (200 nm) / p-type Si substrate with conductive AFM, we verified as-synthesized nanowire has a n-type semiconductor property. (Fig. 5).

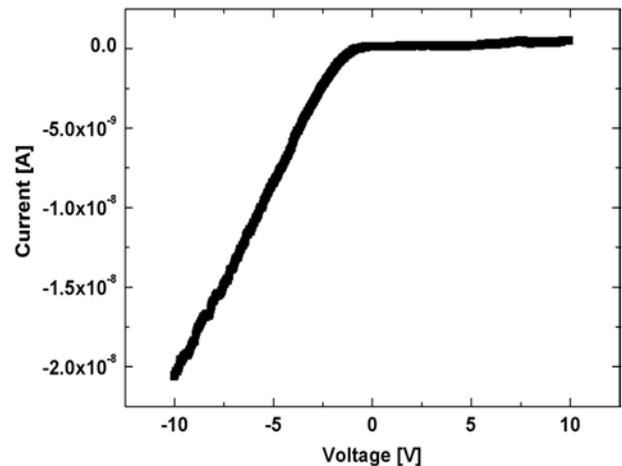


Fig. 6. Schottky diode property of p-type semiconducting O₂ exposed SnO₂ nanowires.

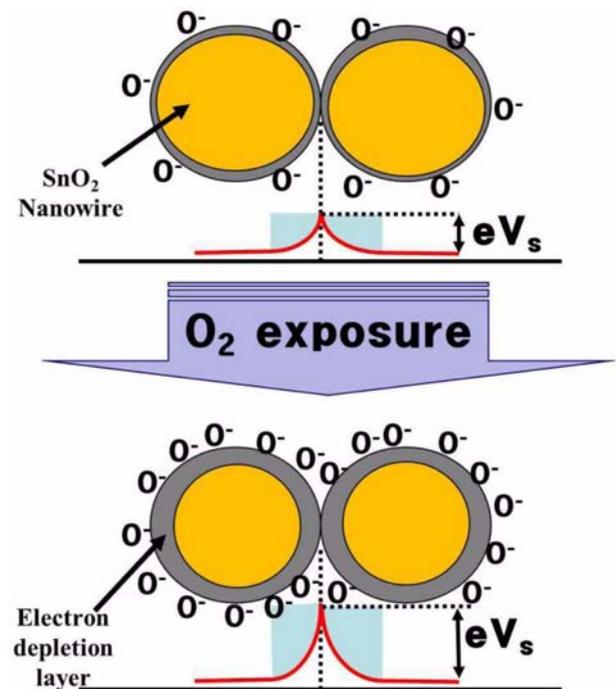


Fig. 7. Schematic diagram of O₂ ionsorption effect on SnO₂ nanowire.

After O₂ exposure, we measured I-V characteristic of metal-semiconductor-metal Schottky diode structure again to verify a type transfer of SnO₂ nanowire and the results shows in Fig. 6. The shape of I-V curve is a typical property of p-type semiconductor, therefore, it seems reasonable to conclude that the semiconducting type of SnO₂ nanowires changed from n-type to p-type when we compare the I-V result of as-synthesized (Fig. 5) and that of O₂ exposed nanowires (Fig. 6).

When the O₂ molecules adsorbed on the surface of the nanowires, the depletion layer near the surface become thick and results in increasing of the potential barrier. As a results, an increased potential barrier disturbed carrier

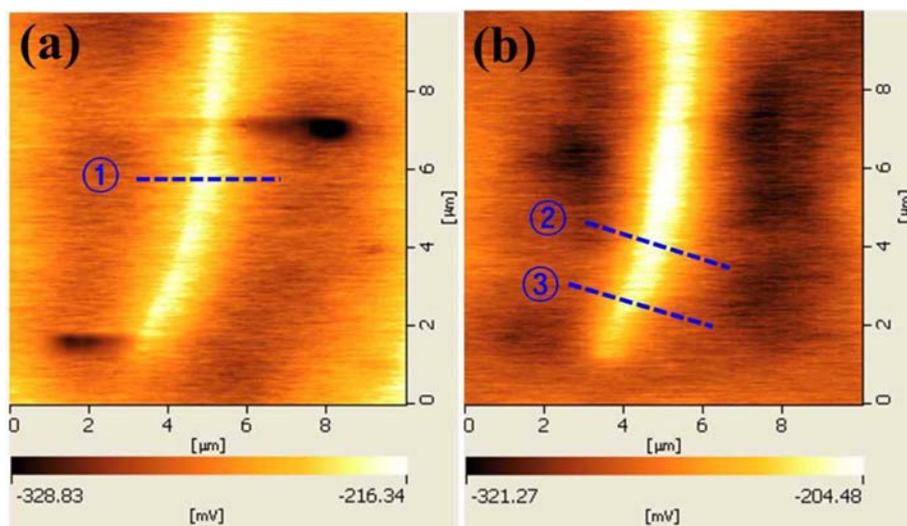


Fig. 8. KFM potential images of (a) as-synthesized SnO₂ nanowires and (b) after O₂ exposure.

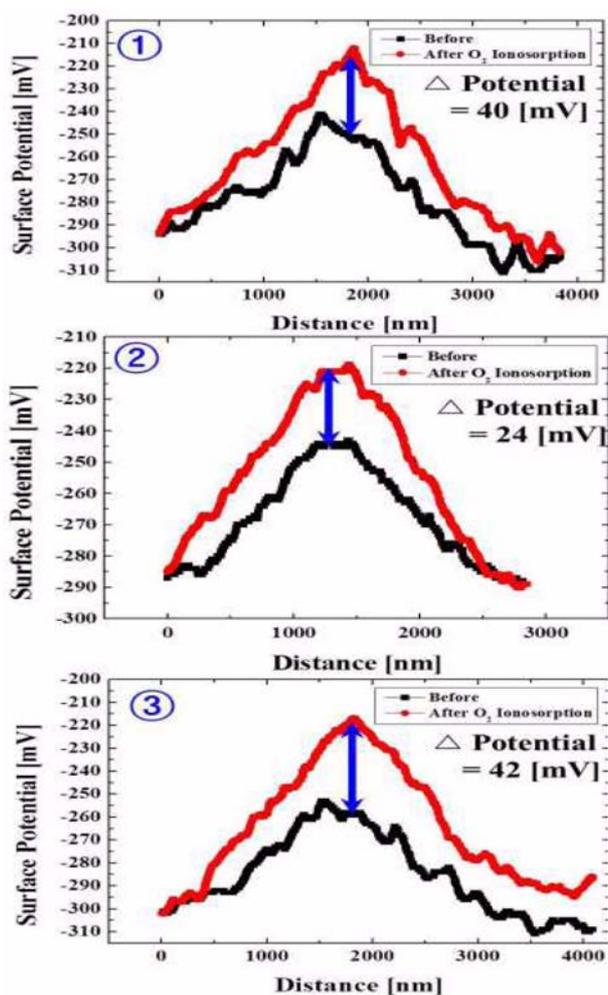


Fig. 9. Change of surface potential profile at the different position in SnO₂ nanowire.

transfer and the conductivity is getting lowered naturally [6-10]. Because ionsorpted O₂ molecules can't be separated easily, the lowered conductivity doesn't recover although concentration of O₂ becomes low.

Conclusions

Kelvin force microscopy (KFM) system has been employed to measure the potential change of a single SnO₂ nanowire which was synthesized on the Au thin film by a thermal process. By using the KFM probing technique, Rh coated conducting cantilever can approach a single SnO₂ nanowire in nano scale and get the potential images with oscillating AC bias between Au electrode and cantilever. Also, during imaging the potential status, we controlled concentration of oxygen in measuring chamber to change the ionsorption rate. From the results of such experiments, we verified that the surface potential as well as doping type of a single SnO₂ nano-wire could be changed by oxygen ionsorption. After the O₂ exposure, the value of surface potential increased and become brighter than that of as-synthesized nano-wire. It means that the doping type of nano-wire changed from n-type to p-type because of the induced depletion layer by O₂ ionsorption.

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